Role of excimer formation and induced photoemission on the Ar metastable kinetics in atmospheric pressure Ar-NH 3 dielectric barrier discharges

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Role of excimer formation and induced photoemission on the Ar metastable kinetics in atmospheric pressure Ar-NH$_3$ dielectric barrier discharges

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Abstract

Tunable diode laser absorption spectroscopy was used to record the space-and time-resolved number density of argon metastable atoms, Ar(1s$_3$) (Paschen notation), in plane-to-plane dielectric barrier discharges operated in a Penning Ar-NH$_3$ mixture at atmospheric pressure. In both low-frequency (LF 650 V, 50 kHz) discharges and dual LF-radiofrequency (RF 190 V, 5 MHz) discharges operated in α-γ mode, the density of Ar(1s$_3$) revealed a single peak per half-period of the LF voltage, with rise and decay times in the sub-microsecond time scale. These results were compared to the predictions of a 1D fluid model based on continuity and momentum equations for electrons, argon ions (Ar$^+$ and Ar$_2^+$) and excited argon 1s atoms as well electron energy balance equation. Using the scheme commonly reported for Ar-based dielectric barrier discharges in the homogeneous regime, the Ar metastable kinetics exhibited much slower rise and decay times than the ones seen in the experiments. The model was improved by considering the fast creation of Ar$_2$* excimers through 3-body reactions involving Ar(1s) atoms and the rapid loss of Ar$_2$* by vacuum ultraviolet light emission. In optically thin media for such photons, they can readily reach the dielectric barriers of the DBD electrodes and induce secondary electron emission. It is shown that Ar$_2$* and photoemission play a significant role not only on the Ar metastable kinetics, but also on the dominant ionization pathways and possible α-γ transition in dual frequency RF-LF discharges.

Keywords: Dielectric barrier discharges, Tunable laser diode absorption spectroscopy, Dual-frequency discharges, Fluid modeling, Argon excited dimer, Photoemission.

1. Introduction

The use of dielectric barrier discharges (DBDs) at atmospheric pressure has experienced uninterrupted growth since the 2000s. Their field of applications is widening, ranging from surface engineering [1–7], control flow [8,9], plasma catalyses [10], pollution control [11], or ozone production [12–14]. This diversification of applications is accompanied by the development of new DBD regimes [15]. In addition to the filamentary and patterned discharge regimes [16,17], homogenous discharges in Townsend, glow or RF α and γ modes are also used [18–22], including for thin film deposition [3,15]. New excitation waveforms for homogenous discharges have also been proposed, including dual-frequency [23–26], frequency-shift keying [27,28] or sawtooth tailored discharges [29]. In low-frequency (LF) plasmas, metastable states play a major role in maintaining the discharge in a homogeneous regime [30]. As a result of their very small diffusion transport, they can remain in the DBD gap from one cycle of the applied voltage to the other. This so-called memory effect can contribute to secondary electron emission at the walls and can induce a pre-ionization of the gas [31,32]. In a Penning gas mixture, for example He with N_2 or Ar with NH_3, metastable species can also induce excitation and ionization at low applied voltage via stepwise excitation and ionization [33–37]. For atmospheric-pressure plasmas sustained in noble gases such as Ar, many authors have reported significant vacuum ultraviolet (VUV) emission [38–43]. While VUV photons at 104.8 and 106.7 nm emanating from Ar 1s resonant states (Paschen notation) are usually trapped due to high populations of ground-state Ar atoms (optically thick medium) [44], the continuum emission linked to argon excimers at 126 nm is characterized by much longer absorption lengths (optically thin medium) [43,45]. Such photons can thus induce a number of additional surface and gas phase phenomena, including secondary electron emission [46]. However, the contribution of such mechanism was never explicitly explored for homogeneous DBDs.

In this work, tunable diode laser absorption spectroscopy (TDLAS) is used to record the population of metastable argon $1s_3$ atoms in plane-to-plane DBDs operated in a Penning Ar-NH$_3$ mixture at atmospheric pressure as a function of time at two locations in the inter-electrode gap for both LF and dual-frequency LF-RF excitations. Through a comparison of TDLAS measurements with the predictions of a 1D fluid model [25,47], it is found that VUV photons emitted by Ar$_2$* dimers, created by 3-body reactions involving Ar(1s) species and two ground state Ar atoms, can induce photoelectron emission at the dielectrics surface of the cathode and can thus play a very significant role on the physics driving Ar-based DBDs.

2. Experimental setup

The DBD examined in this study relies on two plane-to-plane 50 x 10 mm² metallic electrodes covered by 1 mm-thick 70 x 70 mm² dielectric plates made of alumina and separated by a 2mm gap. The discharge zone is thus fixed to a 50 x 10 x 2 mm³ volume. The whole DBD cell is contained in an air-tighten chamber. Before each experiment, the chamber was pumped down to 10^{-5} bar and then flushed with Ar + 200 ppm of NH_3 at 3 standard liters per minute (SLM) flow rate. A needle valve between the chamber and the pumping pipe allows fixing the total pressure in the chamber to 1 bar. Considering the dimensions of the gap, the flow is laminar between dielectric plates. As shown in Figure 1, the top electrode is powered by a 50 kHz LF generator, while the bottom electrode is either grounded or powered by a 5 MHz RF generator. Note that, in a DBD, the applied voltage (V_a) is different from the voltage across the gap (V_{gas} – called "gas voltage" in this paper) due to the voltage drop across both top (V_{ds1}) and bottom (V_{ds2}) dielectric plates ($V_a = V_{ds1} + V_{gas} + V_{ds2}$). This voltage drop is caused by charges present in the discharge, collected on the dielectric surfaces, inducing a modification of the gas voltage. Here, LF and RF waveforms are both produced by a single generator (Keysight 33500B Series), which synchronizes their phases. To produce dual-frequency discharges, the LF signal at 50 kHz is brought to the reactor through an audio amplifier (Crest CC4000) connected to a bridged resistance and a step-up voltage transformer (Boige & Vignal). As for the RF signal at 5 MHz, it is sent to a broadband power amplifier (Prana GN500) linked to a custom-made transformer. In this study, the amplitude of the LF and RF voltages are set to 650 V and 190 V, respectively. Current-voltage characteristics are recorded using a current probe and two high-voltage probes (Tektronix P6015A 75 MHz); all signals are visualized on an oscilloscope (Tektronix MSO56).
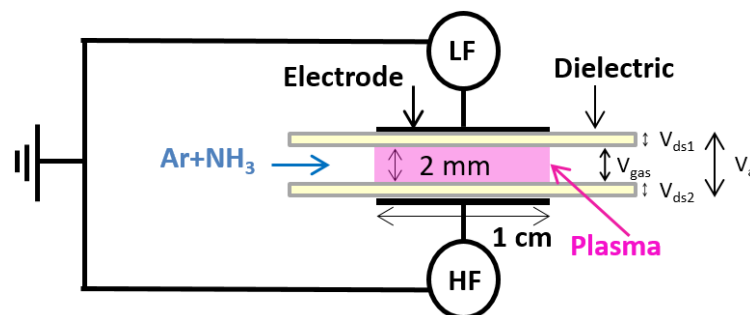

Figure 1. Schematics of the plane-to-plane dielectric barrier discharge with dual-frequency excitation.

3. Measurement of argon metastable atoms

As shown in Figure 2, a tunable diode laser working around 772 nm (DFB, DL100, Toptica) is used to record the number density of Ar metastable atoms by absorption spectroscopy [48–50]. In this wavelength range, atoms in the most populated $Ar(1s_5)$ metastable state can absorb the laser light on $1s_5$-$2p_7$ transition at 772.38 nm and atoms in the other metastable state $Ar(1s_3)$ can absorb the laser light on $1s_3$-$2p_2$ transition at 772.42 nm.
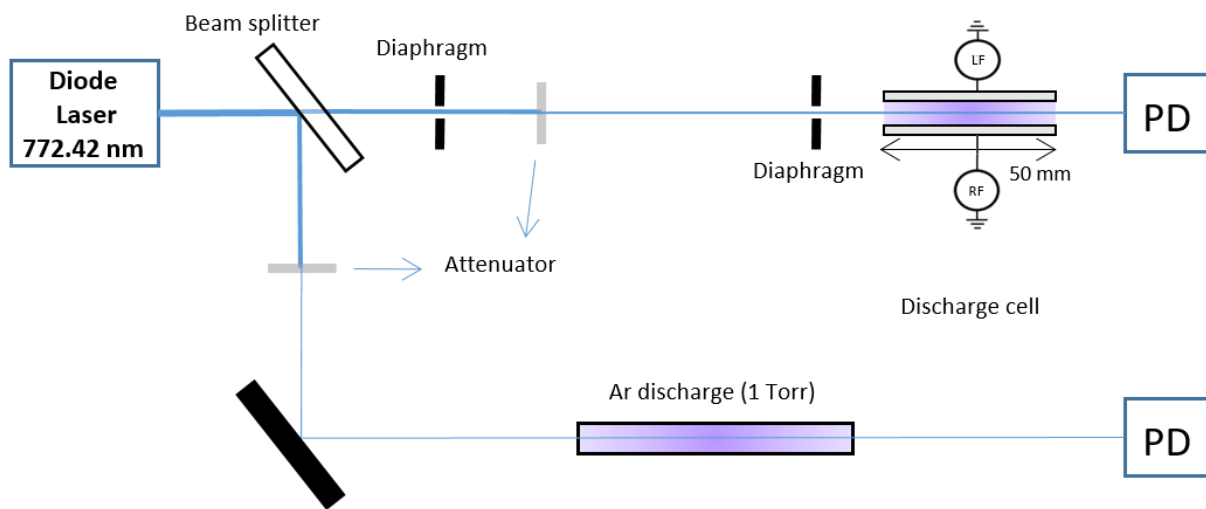

Figure 2. Experimental setup used for determination of the population of Ar $1s_3$ atoms by absorption spectroscopy using a tunable diode laser. PD represents photodiodes.

Figure 3 shows the full absorbance profile when the laser wavelength is scanned around the 772.4 nm range in Ar-based DBDs. Given the closeness of the 772.38 and 772.42 nm transitions, their pressure-broadened absorption profiles overlap under atmospheric pressure conditions. In addition, given the order of magnitude difference in their oscillator strengths (0.0278 and 0.314 for 772.38 and 772.42 nm lines, respectively [51]), the absorption peak intensity of the combined lines is located closer to 772.42 nm. The relative values of the two peak absorbance line profiles and their respective linewidths can be deduced by fitting the experimentally recorded absorbance with two Voigt functions, also shown in Figure 3 by black and red curves. Absolute number densities of metastable argon atoms can be deduced from their respective peak absorbance and width, as described in [48,50–53].
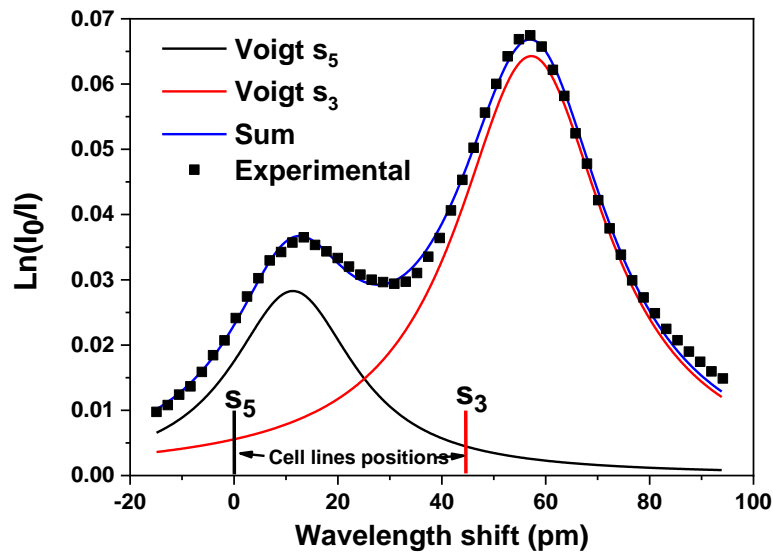
Figure 3. Absorbance profile recorded around 772.4 nm in the Ar-based DBD. Black and red curves are absorbance profiles of 772.38 and 772.42 nm lines, respectively. Positions of these lines in the low-pressure Ar cell are indicated by two vertical lines (red and black for 772.38 and 772.42 nm lines, respectively).

Here, the number density of metastable atoms as a function of time and space is obtained by setting the laser wavelength at the peak of the pressure broadened $1s_3$-$2p_2$ transition, which is shifted by about 13 pm from the vacuum wavelength of this line. Note that, the absorption signal from a low-pressure argon discharge cell (see Figure 2) [48,49] is used to tune the diode laser at the peak position of the $1s_3$-$2p_2$ transition. For both atmospheric-pressure DBD and low-pressure cell, the absorption signals are acquired with fast photodiodes (3.5 ns rise and fall times) and recorded with digital oscilloscope for data analysis and further data processing. In the DBD, the laser beam crosses the gas flow lines (perpendicular to the plan of Fig. 1) such that the absorption length is fixed to 50 mm (see Figure 2). Diaphragms, placed on the laser path before the discharge zone, reduce the laser beam diameter to about 0.5 mm. Spatially-resolved measurements in the 2 mm gap is obtained by moving simultaneously the laser beam, diaphragms system and detector in the inter-electrode space.

Figure 4 presents time-variation curves of the Ar($1s_3$) density recorded at two positions in the inter-electrode gap of the 50 kHz DBD operated in a homogeneous glow regime. In the first case, the laser beam was placed in the middle of the gap, while for the second one it was close to the upper electrode. Current-voltage characteristics are also shown for comparison. Here, data are presented for one full cycle of the applied LF voltage. In the first half-cycle, the top electrode is the cathode, while in the second one this electrode is the anode. As can be seen in Figure 4, a single discharge current peak appears per half cycle of the applied voltage; this is typical of the homogeneous DBDs operated in a

glow discharge regime [33,34]. Similar behaviors can be seen for both Ar(1s$_3$) curves, with rise and decay times in the sub-microsecond time scale. Here, Ar(1s$_3$) reaches a maximum value of 1.1 10^{17}m^{-3} close to the cathode with 3.1 10^{16}m^{-3} in the gas bulk. While similar trends and peak values arise in both half-cycles in the middle of the gap, a dissymmetry between the two half-cycles is observed near the upper electrode. More specifically, an order of magnitude larger density is observed when the top electrode is the cathode (first half-cycle), than when it becomes the anode (second half-cycle). Such dissymmetry is in very good agreement with the physics of Ar-based DBDs operated in a glow regime: i) high-energy electrons, needed for the production of excited argon atoms by electron-impact excitation of ground state Ar atoms, are mainly present inside and at the edge of the cathode sheath; ii) at atmospheric pressure, transport of Ar metastable atoms by diffusion is very slow [30,49,54,55] such that their density is directly linked to their local production and destruction rates.
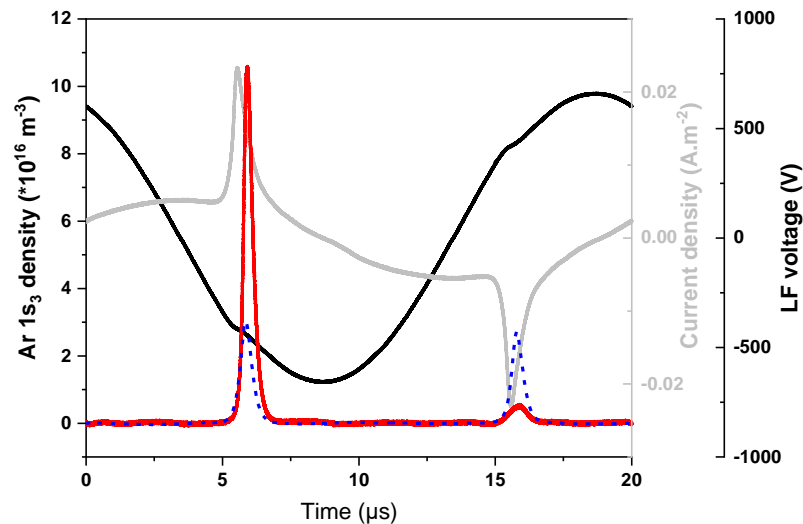

Figure 4. Number density of Ar 1s$_3$ atoms close to the upper electrode (solid) and in the middle of the gap (dash) over a complete cycle of the low frequency excitation (LF 650V, 50 kHz). Applied voltage (black) and total current density (grey, discharge + displacement current density) are also shown for comparison. On first half cycle of the applied voltage, the upper electrode is cathode while on the second half-cycle, the lower electrode is cathode.

Figure 4 further shows that in both half-cycles, the maximum of the Ar metastable density near the cathode arises about 350 ns later than the discharge current peak (linked to the electron population), the delay being slightly shorter in the middle of the gap. This delay most likely results from the ~ 100 ns lifetime of Ar metastable atoms at 1 bar [56]. While the metastable and electron densities increase at the same time with the rise of the applied voltage, Ar metastable atoms tend to accumulate for a longer time than charged species (longer effective lifetimes) [30].

4. Kinetics driving metastable argon atoms

4.1 Fluid model from [25]

For a better understanding of the physics driving plane-to-plane Ar-based DBD sustained by either LF or dual frequency excitations, a 1D fluid model was recently developed by Magnan *et al.* [25]. This model solved the continuity and momentum equations for electrons, argon ions (Ar^+ and Ar_2^+) and excited argon 1s atoms as well electron energy balance equation. Here, even if Ar has four Ar 1s levels, $Ar(1s_2)$, $Ar(1s_3)$, $Ar(1s_4)$ and $Ar(1s_5)$, they are treated as a single $Ar(1s)$ state [57–59] (see additional details below). These above cited equations were coupled to Poisson's equation for the electrical potential and to the standard reaction set displayed in Table 1 for selected collisional and radiative processes in Ar plasmas at atmospheric pressure. Boundary conditions were defined with a secondary electron emission coefficient γ, which describes the probability that an $Ar(1s)$ particle or Ar_2^+ ion creates a secondary electron when interacting with the dielectric surfaces of the DBD cell. In [25], γ was set to 0.1 for ions (Ar^+ and Ar_2^+) and $Ar(1s)$ atoms. It is worth highlighting that in atmospheric-pressure plasmas for which Ar^+ conversion to Ar_2^+ is very fast, the contribution of Ar_2^+ completely dominates the ones of Ar^+ and $Ar(1s)$.

	Reaction	Rate coefficient	Ref
R1)	e + Ar ➔ e + Ar(1s)	f(Te)	[60]
R2)	e + Ar(1s) ➔ 2e + Ar$^+$	f(Te)	[60]
R3)	e + Ar ➔ 2e + Ar$^+$	f(Te)	[60]
R4)	e + Ar ➔ e + Ar	f(Te)	[60]
R5)	e + Ar ➔ e + Ar(>1s)	f(Te)	[60]
R6)	Ar$^+$ + 2Ar ➔ Ar$_2^+$ + Ar	$2.5*10^{-43}$ m^6.s^{-1}	[45][61]
R7)	e + Ar$_2^+$ ➔ Ar(1s) + Ar	$7.4*10^{-14}*Te^{-0.67}$ m^3.s^{-1}	[62]
R8)	Ar$^+$ + cathode ➔ e + Ar	$\gamma_{i\,(Ar+)}$=0.1	[25]
R9)	Ar$_2^+$ + cathode ➔ e + Ar	$\gamma_{i\,(Ar2+)}$=0.1	[25]
R10)	Ar(1s) + cathode ➔ e + Ar	$\gamma_{m\,(1s)}$=0.1	[25]
R11)	Ar(1s) + (NH$_3$) ➔ e + Ar$^+$ + (products)	$4.2*10^{-17}$ m^3.s^{-1}	[63]
R12)	Ar(1s) ➔ Ar	$1.5*10^6$ s^{-1}	[64]

Table 1. Set of gas-phase and surface reactions used in the 1D model of [25]. Here Te is in K.

Note that, the contribution of the 200 ppm of NH_3 present in the nominally pure argon gas, which leads to complex Ar-NH_3 interactions, was not explicitly introduced in the fluid model. Instead, two fictive reactions were included in Table 1: reaction R11) accounted for the primary electron production by Penning ionization of NH_3 by Ar(1s) atoms and reaction R12) accounted for the destruction of Ar(1s) atoms by collisions with Ar atoms and NH_3. The rate coefficients of reaction R11) was taken from [63]. As for the frequency of reaction R12), it was set to the value reported in Table 1 by adjusting the predictions of the model with the measured power, mean and maximal values of the Ar metastable densities [25].

To assess the correctness of this kinetic scheme for time-resolved measurements of Ar metastable atoms, we started by comparing the measured densities of Ar(1s$_3$) atoms to the outcome of the model developed in [25]. For such experimental-model comparison, modelling data were integrated over a 0.5 mm circular region to match the laser beam diameter in the experiments. The comparison was realized with data sets recorded close to the upper electrode, although similar findings were found near the lower electrode of the DBD (not shown). Figure 5a presents the values obtained during a complete cycle of the applied voltage at 50 kHz. Clearly, the model [25] predicts much slower kinetics than the one seen in the experiment, both on the rising and falling side. A similar departure between the model and the experiment can be seen in Figure 5b for the dual-frequency DBD (LF 50 kHz, RF 5 MHz) in the α-γ mode [25,47]. Since reactions R1) to R10) presented in Table 1 are well-established in literature, such disagreement most likely results from the fictive reactions R11) and R12) representing the Penning effect, which are both involving Ar(1s) atoms.

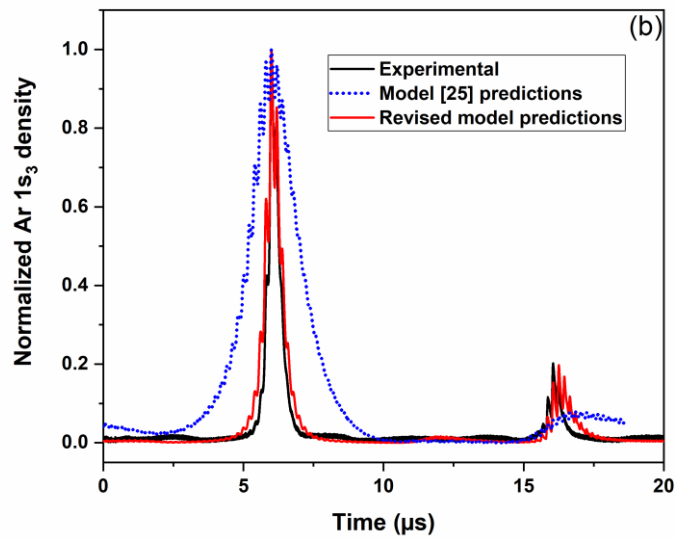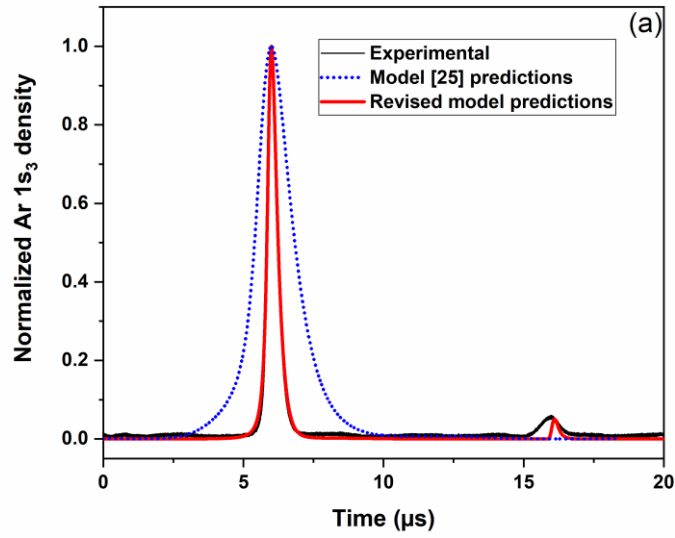*Figure 5. Temporal evolution of the Ar(1s) number density (normalized values): measurements (in black), calculated with the fluid model of [25] (in blue) and with the revised fluid model (in red). The results are shown close to the upper electrode (which was at negative LF voltage in the first half-period and positive in the 2nd one) for (a) 50 kHz LF glow DBD and (b) dual-frequency RF + LF DBD in α-γ mode.*

4.2 Revised fluid model

In line with the findings of Figure 5, reactions R1) to R10) of Table 1 were maintained and fictive reactions R11) and R12) were reconsidered to more explicitly differentiate the contributions of Penning ionization, Penning dissociation, and 3-body conversion of Ar(1s) states. In addition to the creation of Ar excited dimers through 3-body reactions involving Ar(1s) atoms, the loss of Ar_2^* by VUV photons and the VUV-induced secondary electron emission were also added; this yields to the revised kinetic scheme presented in Table 2.

(R13)		Ar(1s) + NH$_3$ ➜ products + Ar	$5.4*10^{-16}$ m^3.s^{-1}	[65]
	(R14)	Ar(1s) + (NH$_3$) ➜ Ar$^+$ + e + (products)	$2.3*10^{-16}$ m^3.s^{-1}	[65], [64]
	(R15)	Ar(1s) + (NH$_3$) ➜ Ar + (products)	$3.1*10^{-16}$ m^3.s^{-1}	[65], [64]
(R16)		Ar(1s) + 2Ar ➜ Ar$_2^*$ + Ar	$1.1*10^{-44}$ m^6.s^{-1}	[55]
(R17)		Ar$_2^*$ ➜ 2Ar + hv (VUV)	$6.0*10^7$ s^{-1}	[43], [61]
(R18)		hv (VUV) + wall ➜ e + wall	$\gamma_{ph}=0.1$	[46]

Table 2. Additional reactions involving excimers and photoemission. (R13) is not explicitly included but introduced through reactions (R14) and (R15), corresponding to Penning ionization and dissociation of NH$_3$, respectively. Note that, no population kinetics for NH$_3$ is introduced in the model: there, (R14) and (R15) frequencies are calculated for 40 ppm of NH$_3$.

Reaction R13) corresponds to the total quenching reaction of Ar(1s$_5$) metastable atoms by NH$_3$. In the revised version of the model, it is decomposed in R14) and R15). Considering the total quenching reaction rate of $5.4x10^{-16}$ m^3.s^{-1} for R13), measured in [65], and the branching ratio of 0.42 for R14), measured in [64], this yields to a reaction rate for Penning ionization of $2.3x10^{-17}$ m^3.s^{-1}. Similarly, for NH$_3$ dissociation by Ar(1s$_5$), the branching ratio is 0.58 [64], which yields to a reaction rate for R15) of $3.1x10^{-17}$ m^3.s^{-1}. Note that, these measured values differ by about a factor of 5 with respect to the one estimated in [63] and previously used for R11) in [25]. Over the range of experimental conditions investigated in this work, 200 ppm of NH$_3$ are injected in the nominally pure argon gas. However, upon discharge ignition, many reaction pathways lead to a significant decrease of this concentration [61]. Inspired by typical precursor fragmentation levels along the gas flow lines of DBD measured in similar

conditions by infrared absorption [66] or operated in various discharge modes [15,67,68], all data were obtained assuming a concentration fraction of 40 ppm.

Reaction R16) corresponds to the 3-body conversion of Ar(1s) atoms leading to excited argon dimers Ar_2^* [69]. This state decays to the dissociative ground state of Ar_2 by producing the VUV continuum emission centered at 126 nm (reaction R17)) [56,61]. Here, the rate coefficient of R16) corresponds to the one measured for $Ar(1s_5)$ [55], and was extended to other Ar(1s) levels in agreement with Arakoni [61]. These VUV photons cannot be absorbed by Ar atoms or Ar_2 in its ground state and by the small amount of NH_3 (optically thin medium) [43]; hence, VUV photons have a long mean free path in the DBD cell (typically ~50 cm [45], i.e. 250 times greater than the inter-electrode gap). Consequently, they can rapidly reach the surface of the dielectric walls, inducing secondary electron emission [46]. The yield for such reaction, γ_{ph}, is assumed comparable to the one of ions and Ar(1s) atoms (R17)) in Table 2. Note that, γ_{ph} includes the contributions of both direct, VUV-induced electron emission and VUV-induced desorption of electrons bound to the plasma-exposed dielectrics by weak polarization interactions [70–73]. In addition, photons are described with an infinite speed: photoemission is therefore instantaneous after the spontaneous dissociation of Ar_2^*. Due to the small inter-electrode gap with respect to the electrode surface, it can be assumed that half of the photons reaches the cathode, the other half goes to the anode [46].

It is worth highlighting that the measurements examine the population of $Ar(1s_3)$, while the model considers all four Ar(1s) state as a block. To note; when accounting for the about 10 times lower oscillator strength of the 772.38 nm line, compared to the one of the 772.42 nm line, Figure 3 reveals that the number density of metastable atoms is about 5 times lower in the $Ar(1s_3)$ state than in the $Ar(1s_5)$ one. This is the ratio between the 2J+1 statistical weights of these states, which have angular momentum J=0 and 2, respectively [51]. A similar rule can be invoked to describe the populations of the resonant $Ar(1s_2)$ and $Ar(1s_4)$ states. According to the resonance radiation trapping theory of Holstein [74,75], extended by Walsh [76], the apparent lifetimes of these states in a 2 mm thick slab of atmospheric-pressure argon gas are 1.2 and 5 µs [44], respectively, which are about 100 times longer than the radiative lifetimes of these states [51]. However, due to the 3-body reaction with two ground state Ar atoms (described by R16)), and to the quenching by NH_3 (described by the sum of R14) and R15)), the effective lifetime of the four Ar(1s) states, metastable as well as resonance states, decreases by at least one order of magnitude ($\approx$ 100 ns). Considering comparable rate coefficients reported for different Ar(1s) states for R13) in [65] and for R16) in [55], the population densities of these states become proportional to their respective production rates by electron impact excitation, which follow their respective statistical weights 2J+1. Moreover, population transfers between the four Ar(1s) states, induced by collisions with Ar atoms [55,77] and electrons [57,58], help for the

establishment of this statistical population distribution. Hence, the angular momentum J being 1, 0, 1 and 2 for Ar(1s$_2$), Ar(1s$_3$), Ar(1s$_4$) and Ar(1s$_5$) states, respectively [51], their relative population densities should follow 3:1:3:5 ratios. Hence, the total density of excited argon atoms in the four Ar(1s) states calculated by the model corresponds to 12 times the measured density of the Ar(1s$_3$) level.

Revised values of the normalized metastable number densities are presented in Figure 5a for the LF discharge (50 kHz) and dual-frequency DBD (LF 50 kHz, RF 5 MHz) operated in the α-γ mode [25,47]. Clearly, much better agreement is observed with the revised version of the model than with the one originally developed by Magnan *et al.* [25]. Hence, in addition to the higher reaction rates for Penning ionization and dissociation (R14) and R15)), the fast creation of Ar$_2$* R16) and its rapid radiative decay, leading to VUV emission and secondary electron emission (R17) and R18)), allow a much better description of the time variation of Ar(1s) populations in both LF and LF-RF DBDs, with much more prominent rise and decay times.

A very small peak of Ar(1s) also appears in Figure 5 close to the anode when Ar$_2$* and photoemission resulting from VUV photons are included in the model. This aspect was examined in more details by plotting the Ar(1s) mapping over time and space. Results are presented in Figure 6a. One can see that the maximum of Ar(1s) is close to the cathode, but the high-density area extends into the gap and reappears close to the anode. Over the range of experimental conditions investigated, Ar(1s) atoms are mainly created by R1), i.e. by high-energy electrons [25], and transport by diffusion is negligible [30,49,54,55]. Spatial variation of the electric field along the gap when the population of Ar(1s) species increases at the anode are presented in Figure 6b with and without chain reactions leading to the photoemission by VUV photons. Compared to [25], the revised kinetic scheme used in the fluid model leads to an increase of the electric field in the gas bulk and near the anode. This necessarily implies a more prominent electron drift from the cathode to the anode and thus a more important creation of Ar(1s) atoms by high-energy electrons in the anode region.
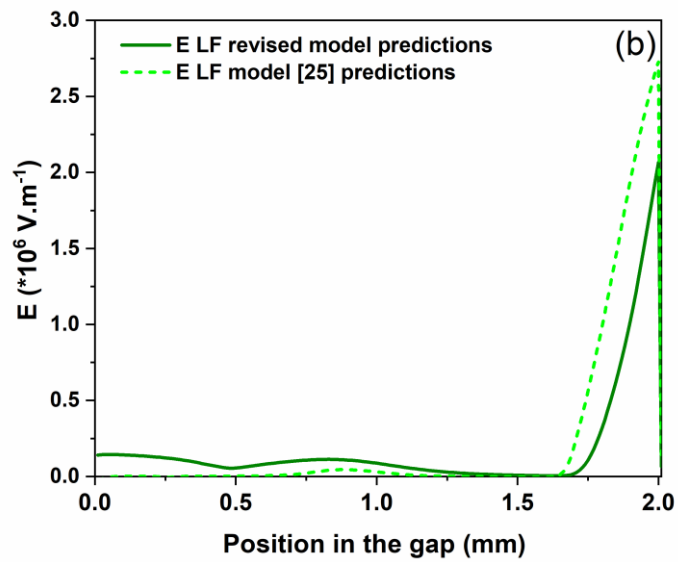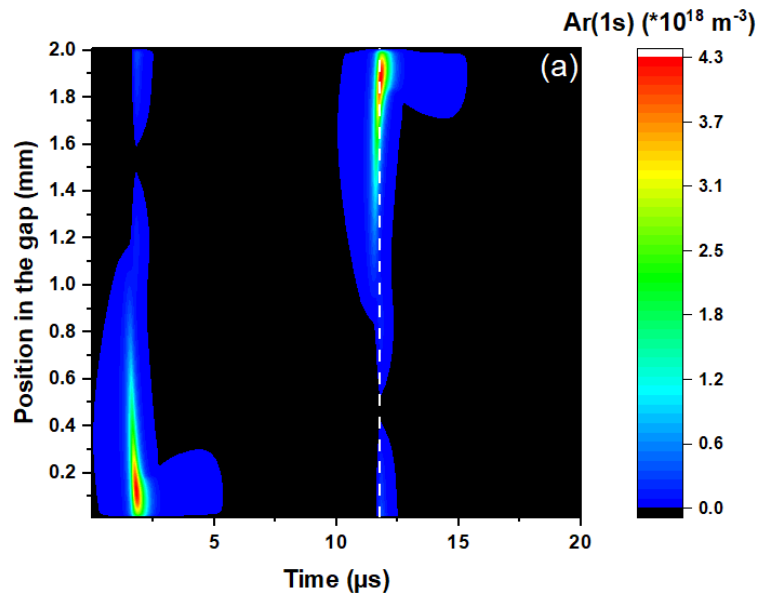
Figure 6. a) Ar(1s) number density evolution over space and time in the LF DBD, b) spatial profile of the electric field along the gap when Ar(1s) is maximum at the anode (vertical line in a). In b), the results for the electric field are shown with the model used in [25] and with the revised version developed in this work.

5. Consequences of excimer formation and photoemission on Ar-based DBDs in LF and LF-RF regimes

5.1. Discharge kinetics

The introduction of the population kinetics of Ar_2^* (formation through reaction R16) and loss through reaction R17)) and photoemission by VUV photons (reaction R18)) strongly modify the physics driving Ar-based DBDs in both LF and LF-RF DBD regimes.

Table 3 summarizes important modifications on the dominant creation and loss terms of both Ar(1s) atoms and electrons. For Ar(1s), electron-impact excitation represents the dominant creation pathway in both LF and LF-RF regimes. As for the losses, Penning dissociation accounts for 88% of Ar(1s) consumption when using the reaction set provided by Magnan *et al.* [25]. In the revised model, over the range of experimental conditions investigated, the contribution of Penning dissociation decreases, and the dominant loss mechanism becomes the creation of Ar_2^*. In the same way, consumption of Ar(1s) states for Penning ionization also reduces. In line with these results, one may think that the more prominent rise and decay times observed for the population of metastable argon atoms in Figure 5a and Figure 5b with the revised model is entirely linked to the Ar_2^* kinetics, and not to photoemission. However, if R18) is removed from the model, discharge breakdown no longer occurs, even for very high amplitudes of the LF voltage. This feature is obviously due to the high loss rates of Ar(1s) atoms, which can no longer bring energy to the discharge. It also shows that the creation of Ar(1s) atoms is largely related to photoemission.

		50 kHz LF		50 kHz LF + 5 MHz RF	
		Model of [25]	Revised model	Model of [25]	Revised model
Creation of Ar(1s)	e-Ar_2^+ recombination (%)	4	<0.1	1	<0.1
	Direct excitation (%)	96	100	99	100
Ar (1s) losses	To the walls (%)	<0.1	<0.1	<0.1	<0.1
	Penning ionization (%)	12	3	12	3
	NH_3 dissociation (%)	88	4	88	4
	Creation of the dimer Ar2* (%)	--	93	--	93
Creation of e-	Penning ionization (%)	79	49	82	52
	Direct ionization (%)	14	30	9	23
	Secondary emission (%)	7	21	9	25
e- losses	To the walls (%)	76	92	94	98
	e-ion recombination (%)	24	8	6	2

Table 3 Space- and time-averaged contribution of the different mechanisms to the creation and loss of Ar(1s) and electrons for LF 50 kHz 1000 V and dual-frequency 50kHz 750 V + 5MHz 350 V

As for the electrons,

Table 3 shows that while Penning and direct ionization were the dominant ionization pathways in the initial model [25,47], about 3 times more electrons are now created by photoemission at the walls with the addition of the Ar₂* kinetics and photoemission (R15)). However, the contribution of Penning ionization remains larger than the one of Ar direct ionization. As said previously, even if only 3% of Ar(1s) consumption are involved in Penning ionization, this reaction remains necessary for the discharge ignition. If Penning ionization is entirely removed from the revised model, the discharge no longer ignites, which fully supports previous experimental findings demonstrating the importance of

the NH$_3$ Penning gas mixture in the physics driving Ar-based, low-frequency DBDs [18,23]. Experimentally, in dual-frequency DBDs, the γ mode is never reached without NH$_3$ and thus without Penning ionization contributions. Since direct ionization of NH$_3$ is fully negligible over the range of experimental conditions investigated [61], this must be linked to Penning ionization contributions.

Table 3 further reveals that the relative contribution of electron losses to the walls increases with respect to recombination processes in the bulk. The explanation is that with addition of the Ar$_2$* kinetics and photoemission, the contribution of secondary electrons increases, creating more ions and electrons in the sheath. Ions are thus more effectively lost to the cathode surface, while electrons can more easily drift to the anode surface.

5.2. RF α ➔ RF α–γ transition criterion in dual frequency RF-LF

In LF-RF Ar-NH$_3$ DBDs, a transition from α to α-γ can occur with the increase of the LF voltage [25,47]. Under atmospheric pressure conditions, the first mode is called α or Ω mode, and is characterized by an ohmic heating and electron energy dissipation in the bulk [20,22]. The second mode is called α-γ mode: during each half cycle of the LF voltage, electron Joule heating and electron energy loss reach a maximum in the sheath region for some µs [78]. This transient γ mode is observed when the gas voltage amplitude reaches a high enough value. Like in a LF DBD, when the γ mode is reached, the gas voltage decreases due to the charge of the dielectrics. Consequently, the maximum of the gas voltage is observed just after the transition from α to γ mode, and the γ mode duration is limited [20,47]. In this γ mode, the contribution of secondary electrons to the gas ionization becomes large enough to reach the self-sustainment criterion in the cathode sheath [47,79]:

$$\frac{\gamma_i \, \langle \Gamma_{i,sheath} \rangle_{RF}}{\langle \Gamma_{SEE} \rangle_{RF}} > 1 \, , \qquad (1)$$

where $\langle \Gamma_{i,Sheath} \rangle_{RF}$ is the maximum value at a given time of the LF voltage of the total ion flux through electron Joule heating and electron multiplication in the cathode sheath [47]

$$\Gamma_{i,sheath}(t) = \int_{cathode}^{sheath \ edge} S_i(x,t)dx \, , \qquad (2)$$

where S_i is the volume production rate of ions. In Equation (2), the integration is realized over the sheath thickness (In practice, this is done by means of a weighting function defined as $W(x) = 1 - ne(x)/ni(x)$, which varies smoothly from ≈1 at the wall to ≈0 in the plasma bulk; the source term S_i is then multiplied by W(x) and then integrated from the electrode to the center of the plasma, as explained in [47]). As for $\langle \Gamma_{SEE} \rangle_{RF}$ in Equation (1), it corresponds to the maximum at a given time of the LF voltage of the secondary electron flux emitted from the cathode wall in the DBD cell. Note that, the criterion given by Equation (1) is obtained with values averaged over one RF cycle because the self-sustainment criterion involving ion transport back to the wall is too slow to react to the RF fluctuations of the electric field in the sheath [47]. Generally, the transition from α to α-γ mode is related to secondary electron emission by ion bombardment only (γ_i); in line with the findings of this work, the secondary electron emission contribution by photons (γ_{ph}) must be added such that the self-sustainment criterion becomes
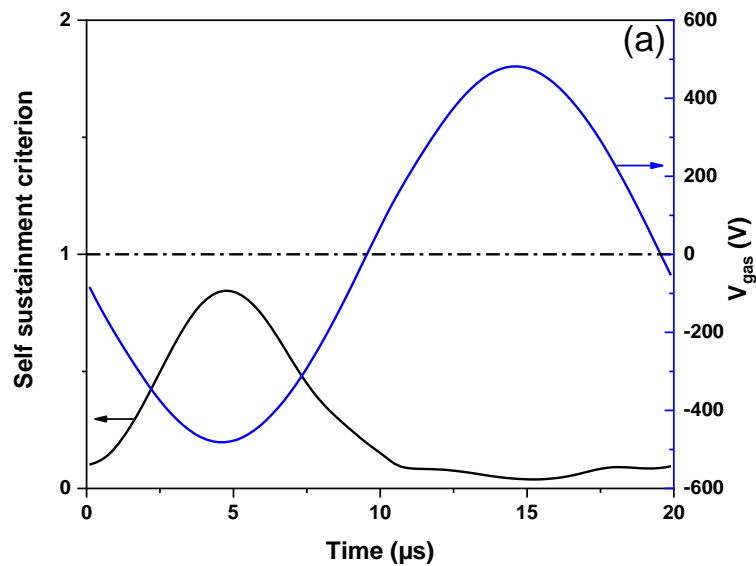
$$\frac{\gamma_i \, \langle \Gamma_{i,sheath} \rangle_{RF} + \frac{1}{2} \gamma_{ph} \eta \, \langle \Gamma_{Ar(1s),sheath} \rangle_{RF}}{\langle \Gamma_{SEE} \rangle_{RF}} > 1, \tag{3}$$

where $\langle \Gamma_{Ar(1s),sheath} \rangle_{RF}$ is the maximum value at a given time of the LF voltage of the Ar(1s) flux in the cathode sheath

$$\Gamma_{Ar(1s),sheath}(t) = \int_{cathode}^{sheath \; edge} S_{Ar(1s)}(x,t)dx \, , \tag{4}$$

where $S_{Ar(1s)}$ is the volume production rate of Ar(1s). In Equation (3), η corresponds to the fraction of the argon metastable atoms in the sheath that lead to the creation of Ar_2^* and then to VUV photons. Over the range of experimental conditions investigated, with the reaction set presented in Table 2, η is approximately constant ($\eta \cong 0.926$) due to the constant frequencies of all the dominant conversion processes of Ar(1s). It follows that the maximum photon flux in the sheath is directly proportional to the maximum Ar(1s) flux in the sheath. Since $\eta \, \langle \Gamma_{Ar(1s),sheath} \rangle_{RF}$ includes photons produced in the cathode sheath but towards both the anode and the cathode, the ½ factor in Equation (3) accounts for the fact that, in optically thin media for VUV photons, only half of the photons reaches the cathode (the other half reaches the anode).

Figure 7 presents the self-sustainment criterion calculated by the Equation (3) as a function of time during a LF period of the dual-frequency discharge. The results are shown for two amplitudes of the LF voltage: in (a), the LF voltage remains below the value required to induce a transition from α to γ mode, while in (b), the LF voltage is such that a transient γ mode occurs. Based on Equation (2), the discharge can transit to the γ mode if the self-sustainment criterion becomes greater than 1 over a given time frame of the LF voltage. In Figure 7 (a), this criterion is never satisfied whereas in Figure 7 (b), it is fulfilled between 0.85 and 2.5 µs. In such conditions, the sheath becomes self-sustained. The presence of the γ mode can be further confirmed by the gas voltage (averaged over one RF cycle) behaviors also displayed in Figure 7. While the gas voltage remains more or less sinusoidal in Figure 7 (a), a rapid gas voltage drop can be seen in Figure 7 (b) due to the corresponding charge of the dielectrics.
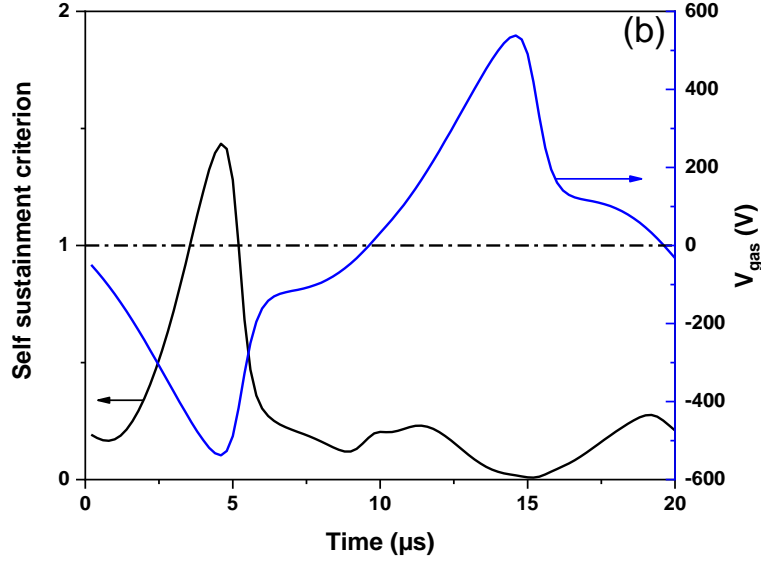
Figure 7. Self-sustainment criterion plot as a function of time during a complete cycle of the LF voltage. Here, the criterion corresponds to left-hand-side of Equation (3) (in black). Gas voltage values are also shown (in blue). Results are presented for a dual frequency LF (50 kHz) – RF (5MHz), V_{RF} = 350 V, (a) V_{LF} = 600 V, (b) V_{LF} = 650 V

In this framework, Figure 8 presents the self-sustainment criterion, at the moment when $|V_{gas}|$ is maximum, calculated by the left-hand-side of Equation (3) as a function of the amplitude of the LF voltage. Again, when the ratio exceeds 1, i.e. when each secondary electron produces enough ions and Ar(1s) in the sheath to cause the emission of one or more new secondary electrons, the discharge transits to the γ mode, i.e. the sheath becomes self-sustained [25,47]. As can be seen, the transition occurs for different LF voltage amplitudes depending on the specific set of the chosen γ_i and γ_{ph} values. For γ_i=0.1, the minimum LF voltage required for the α-γ mode transition decreases as γ_{ph} increases. Hence, for a more important electron production through photoemission, a lower LF voltage is sufficient to reach the number of ionizations provided by the self-sustainment criterion. On the other hand, Figure 8 shows that γ_i has only little influence on the value of the LF voltage required for the transition. This is related to the long drift time of ions to the cathode compared to the γ mode duration, which limits the influence of γ_{ions} on the α-γ transition voltage. More precisely, the ions drift from the sheath edge to the cathode lasts about 1 μs, which is the magnitude of the duration of the γ mode. Consequently, ions produced at the sheath edge during the γ mode only have little influence on the γ mode transition.
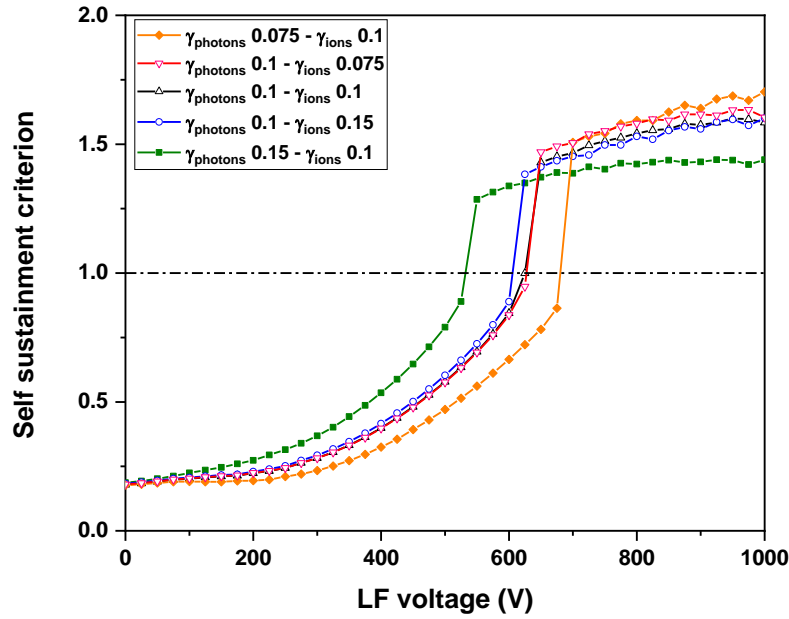
Figure 8. Self-sustainment criterion plot as a function of the amplitude of the LF voltage in dual-frequency LF-RF DBDs. Here, the criterion corresponds to left-hand-side of Equation (3).The results are shown for various γ_i and γ_{ph} values.

6. Conclusion

Through a comparison between the measured and simulated populations of metastable argon atoms, the objective of this work was to highlight the role of excimer formation, followed by the VUV emission and photoemission on the Ar metastable kinetics in Ar-NH$_3$ dielectric barrier discharges at atmospheric pressure. The model initially developed to describe Ar-based dual-frequency DBDs [25,47] was not able to reproduce the time variation of Ar(1s) atoms density characterized by rise and decay times in the microsecond time scale. On the other hand, including Ar$_2$* formation, Ar$_2$* spontaneous deexcitation leading to VUV continuum emission, and the induced photoemission at the walls, provided much more accurate Ar metastable kinetics for both low-frequency (50 kHz) and dual frequency (50 kHz - 5 MHz) excitations. In addition, the apparition of a peak in the density of metastable argon atoms at the anode was also better described using photoemission. It was shown that this peak of Ar(1s) atoms density is not directly linked to the consumption-creation balance of Ar(1s) atoms, but rather to the production of an electron beam passing through the discharge during the LF breakdown. Ar$_2$* and photoemission further played a significant role on the ionization kinetics : while Penning were the truly dominant ionization pathways in the initial model [25,47], the part of electron's creation by photoemission and direct ionization increases to become of the order of

magnitude of that of Penning ionization in the refined version of the model. Photoemission was also demonstrated to influence the transition from α to α-γ mode.

7. Acknowledgments

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